Questionnaire of edaWorkshop11 and CATRENE DTC

The poster exhibition of the submitted papers was





1 V									
1. Keynotes									
More than Moore - Challenge (M. Brillouët)	es and Opportunities for Europe	excellent	Ο	Ο	Ο	0	Ο	unsufficient	
Real-world Applications of Smart Environments in the Home (B. de Groot)		excellent	0	Ο	0	0	0	unsufficient	
Gaining 10x in Power Efficiency in the Next Decade in Consumer Products (G. Teepe / P. Magarshack))		excellent	0	0	0	0	0	unsufficient	
Design and Verification of Dependable Analog Systems (L. Hedrich)		excellent	0	0	0	0	0	unsufficient	
2. Sessions									
Healthcare (May 10)			excellent O		Ο	Ο	0	unsufficient	
System Design Methodologi	excellent	excellent O O O		0	0	Ο	unsufficient		
Multicore Architecture (May 10)		excellent	Ο	0	Ο	0	Ο	unsufficient	
High Level AMS Design (May 11)		excellent	Ο	Ο	Ο	Ο	Ο	unsufficient	
Design for Yield and Reliability (May 11)		excellent	0	0	0	0	0	unsufficient	
Robust Design (May 12)		excellent	Ο	Ο	Ο	Ο	Ο	unsufficient	
Analog Synthesis and Optimization and 3D-Circuits (May 12)		excellent	0	0	0	0	0	unsufficient	
3. Panel Discussions									
Network on Chip - Alternative Solutions and Future Directions (May 10)		excellent	0	0	0	0	0	unsufficient	
More than Moore – the Most Important Driver of Microelectronics! Or? (May 11)		excellent	0	0	0	0	0	unsufficient	
4. Presentations of IKT 2020 projects									
HONEY	technical aspect	excellent	0	0	0	0	0	unsufficient	
(May 11, G. Georgakos)	commercial aspect	excellent	Ο	Ο	0	0	Ο	unsufficient	
ROBUST	technical aspect	excellent	Ο	Ο	0	0	Ο	unsufficient	
(May 12, M. Radetzki)	commercial aspect	excellent	0	0	0	0	0	unsufficient	
SYENA (May 12, A. Graupner)	technical aspect commercial aspect	excellent excellent	0	0 0	0	0 0	O O	unsufficient unsufficient	
s, -z, Siddpilot,	22	5,130110111	•	•	•	J	•	3001010111	
5. Poster Exhibition (May 11-12)									
The poster exhibition of the I	excellent	Ο	Ο	0	0	Ο	unsufficient		
			0	0	0	_	0		

unsufficient

excellent O O O O

6. About the event	general								
The professional aspec	et of the event v	vas	excellent	0	0	0	0	0	unsufficient
The event supported m	ny personal net	working	excellent	0	0	0	0	0	unsufficient
				< 20%		ntil 609	% until 80		00%
I knew x percent of the	e participants pe	ersonally		Ο	0	0	0	0	
The conference location Dresden was		excellent	0	0	0	0	0	unsufficient	
My expectations were	expectations were more than fulfilled		completely agree	0	Ο	0	0	0	completely disagree
The overall impression	was good		completely agree	0	0	0	0	0	completely disagree
7. About the joint e	vent "edaWo	orkshop11	and CATRENE DTC	,					
I have been participant at an edaWorkshop before					yes	0	Ο	no	
I have been participant (formerly MEDEA+ DA		DTC before			yes	0	0	no	
The co-location of both	events was a	good idea	completely agree	0	0	0	0	0	completely disagree
I will participate next ye	ear's edaWorks	hop	in any case	0	0	0	0	Ο	not at all
I will participate next ye	ear's CATRENE	DTC	in any case	0	0	0	0	0	not at all
8. Main reasons for	attendance								
O Refresh existing contacts O Speaker/e		exhibitor	O edaWorkshop11						
O Make new contacts O Techni			l interest	nterest O CATRENE [
O Other:									
9. How did you get	to know abo	out the eda	Workshop11 and C	ATRI	ENE DT	C ?			
O E-Mail	O WWW		O Mail	O Fa	acebook/	Twitt	ter/Link	edIn	
O Press	O Colleagues/Friends O Known from last				s event				
O Other:									
10. More comment	s								

Many thanks for completion the questionnaire!

Please return this form to the registration desk before leaving or fax it to **+49 511 762-19695**.